

PATENT

Attorney Docket No.: 728-208 (YOR9-2001-0270 US)

AMENDMENTS TO THE CLAIMS

1-11. (Canceled)

12. (Currently Amended) An array of planar T-RAM cells comprising:
a plurality of T-RAM cells, said plurality of T-RAM cells being arranged in an array and fabricated over a substrate, each of said plurality of T-RAM cells including a buried vertical thyristor and a horizontally stacked pseudo-TFT transfer gate having a body of a majority portion of single crystalline material using an n+ layer below it as seed material by a epitaxial lateral overgrowth technique, said horizontally stacked pseudo-TFT transfer gate including a source/drain and body, said thyristor being buried underneath said horizontally stacked pseudo-TFT transfer gate, wherein said horizontally stacked pseudo-TFT transfer gate covers at least a portion ~~the entire top surface~~ of said thyristor, and further wherein the top surface of said horizontally stacked pseudo-TFT transfer gate forms a co-planar top surface of each said horizontally stacked pseudo-TFT transfer gate of each said T-RAM cell,
wherein each of the plurality of T-RAM cells has a size of less than or equal to $6F^2$.

13-14. (Cancelled)

15. (Previously Presented) The array according to Claim 12, wherein said substrate is a semiconductor SOI or bulk wafer.

16. (Previously Presented) The array according to Claim ~~13~~¹², wherein a base of said thyristor is surrounded by a surrounded gate.

17. (Previously Presented) The array according to Claim 12, wherein said planar top surface of each T-RAM cell provides for fabrication of wordlines, said wordlines being fabricated over said planar top surface of said T-RAM cells, said wordlines for interconnecting said T-RAM cells.

18-31. (Canceled)